



Ti(C,N) and (Ti,Al)N hard wear resistant coatings

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The technique of depositing of the hard and thin coatings is one of the most spectacular aspect of the materials engineering development in the last years. The physical vapour deposition (PVD) method of hard coating are widely used today for enhanced performance and have been evolved, because they can be deposited at temperatures much lower than those commonly needed for the chemical vapour deposition (CVD) of coating [7-8].

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